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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	. ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/516,708	12/03/2004	Takuo Funaya	Q85154	6730	
23373 7	590 09/25/2006		EXAM	EXAMINER	
SUGHRUE N	MION, PLLC	EDMONDSON, LYNNE RENEE			
	LVANIA AVENUE, N.V	V.	ART UNIT	PAPER NUMBER	
SUITE 800 WASHINGTO	N, DC 20037		1725		
	•		DATE MAILED: 09/25/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)					
Office Action Comments		10/516,708	FUNAYA ET AL.					
Office Action Summa	ary	Examiner	Art Unit					
		Lynne Edmondson	1725					
The MAILING DATE of this co Period for Reply	mmunication app	ears on the cover sheet with the c	orrespondence ad	dress				
A SHORTENED STATUTORY PER WHICHEVER IS LONGER, FROM - Extensions of time may be available under the p after SIX (6) MONTHS from the mailing date of t - If NO period for reply is specified above, the mail - Failure to reply within the set or extended period Any reply received by the Office later than three earned patent term adjustment. See 37 CFR 1.3	THE MAILING DA rovisions of 37 CFR 1.13 his communication. kimum statutory period w for reply will, by statute, months after the mailing	ATE OF THIS COMMUNICATION 16(a). In no event, however, may a reply be tim rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI						
Status								
1) Responsive to communication	n(s) filed on 17 Ju	ulv 2006						
2a) ☐ This action is FINAL .	 ☑ Responsive to communication(s) filed on <u>17 July 2006</u>. ☑ This action is FINAL. 2b) ☐ This action is non-final. 							
<u>'</u>	· —							
• •	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
	pruotico unaci E	y parto quayio, 1000 O.D. 11, 40	0.0.210.					
Disposition of Claims								
4)⊠ Claim(s) <u>9-13 and 15-36</u> is/ar	e pending in the a	application.						
4a) Of the above claim(s)		vn from consideration.						
5) Claim(s) is/are allowed								
)⊠ Claim(s) <u>9-13 and 15-36</u> is/are rejected.							
7) Claim(s) is/are objecte	d to.							
8) Claim(s) are subject to	restriction and/or	r election requirement.						
Application Papers				/				
9)⊠ The specification is objected to	by the Examine	r.						
10)⊠ The drawing(s) filed on 31 Aug	10)⊠ The drawing(s) filed on <u>31 August 2005</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
Applicant may not request that a	ny objection to the	drawing(s) be held in abeyance. See	37 CFR 1.85(a).					
		ion is required if the drawing(s) is obj		R 1.121(d).				
11)☐ The oath or declaration is obje	cted to by the Ex	aminer. Note the attached Office	Action or form PT	O-152.				
Priority under 35 U.S.C. § 119								
12)⊠ Acknowledgment is made of a	claim for foreign	ndority under 35 H.S.C. & 119(a)	-(d) or (f)					
a) ⊠ All b) □ Some * c) □ Non		priority under 33 3.3.3. § 113(a)	-(a) or (i).					
1. ☐ Certified copies of the p		s have been received						
		s have been received in Application	on No					
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application from the Inte	•	•	a in this reational	Olago				
			d					
* See the attached detailed Office action for a list of the certified copies not received.								
Attachment(s)								
1) $igotimes$ Notice of References Cited (PTO-892) 2) $igodius$ Notice of Draftsperson's Patent Drawing Re	aview (PTO 049)	4) Interview Summary Paper No(s)/Mail Da						
3) Information Disclosure Statement(s) (PTO-		5) Notice of Informal P)-152)				
Paper No(s)/Mail Date	,	6) Other:						
Data de la Trada de Office								

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 9-13 and 15-36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shoji et al. (US 2006/0071051 A1) in view of Hampl, Jr. (USPN 4180415).

Shoji teaches an electronic component soldered to a board (paragraph 3) by soldering with a Pb free solder comprising up to 9% Zn, at least 0.05% Bi (paragraphs 13-16) and a combined impurity level of Ag among other elements of less than 1% in a balance of Sn (paragraph 34). Powder diameter is 1 to 20 microns (paragraphs 42 and 43). Solder is mixed with 8-14% flux (paragraph 24). However the particular Ag amount is not disclosed.

Hampl teaches a joining material comprising an impurity level of less than 0.1% Ag (col 4 lines 5-9).

It would have been obvious to employ less than 0.1% as Ag is included in a impurity amount. 0.8% Ag would be included in the less than 0.1% range. Larger amounts of Ag would cause considerable changes in solder melting temperature. It is further noted that less than 0.1% is typically considered an impurity level in the art.

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Response to Arguments

3. Regarding applicant's argument that Shoji does not teach silver present in an amount greater than 0.001 but smaller than 0.1%. Paragraph 13 teaches impurities of up to 1% which may be Ag (paragraph 34). While 1% is a relatively high impurity level, this impurity level has a maximum range endpoint that is higher than the instant level. Ag is one of many elements which may be present. Hampl confirms that states as is more common in the art that 0.1% is a common impurity level. As both references teach that these amounts are present, they do not teach away from their presence. Although not necessarily or optimally desirable, an amount up to 0.1% Ag may be present. While the desire to avoid may be present, that term "unavoidable" implies that it will be present whether desirable or not. Ag would not typically be selected, particularly in such a small amount, however it is very likely to be present. An amount up to 1%, includes amounts up to but not including 0.1%. It is noted that the claims use the term comprising not consisting of or consisting essentially of.

Although applicant found unexpected results, it would be expected that the same composition would give similar results.

Therefore the 103 rejection of claims 9-13 and 15-36 as obvious over Shoji in view of Hampl stands.

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Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Murata et al. (USPN 6241942 B1), Munekata et al. (US 2004/0062679 A1, up to 4% Ag), Yamaguchi et al. (US 2001/0025875 A1, powder size), Taguchi et al. (USPN 3896172 B2, flux amount).

5. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lynne Edmondson whose telephone number is (571) 272-1172. The examiner can normally be reached on Monday through Thursday from 6:30 a.m. to 5 p.m.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Patrick Ryan can be reached on (571) 272-1292. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

> Lynne Edmondson Primary Examiner (// 2

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LRE